

Advances in crystalline silicon solar cell technology for industrial mass production

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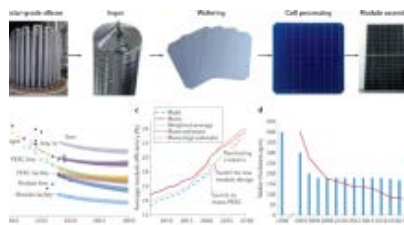
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Abstract

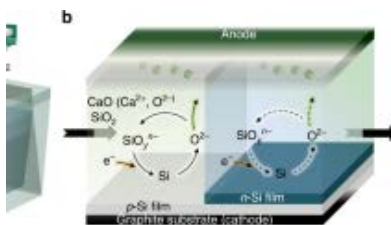
Crystalline silicon photovoltaic (PV) cells are used in the largest quantity of all types of solar cells on the market, representing about 90% of the world total PV cell production in 2008. Crystalline silicon solar cells are also expected to have a primary role in the future PV market. This article reviews the current technologies used for the production and application of crystalline silicon PV cells. The highest energy conversion efficiency reported so far for research crystalline silicon PV cells is 25%. Standard industrial cells, however, remain limited to 15–18% with the exception of certain high-efficiency cells capable of efficiencies greater than 20%. High-efficiency research PV cells have advantages in performance but are often unsuitable for low-cost production due to their complex structures and the lengthy manufacturing processes required for fabrication. Various technologies for mono- and polycrystalline PV cells are compared and discussed with respect to the corresponding material technologies, such as silicon ingot and wafer production. High energy conversion efficiency and low processing cost can only be achieved simultaneously through the development of advanced production technologies and equipment, and some of the latest technologies that could lead to efficiencies of greater than 25% and commercially viable production costs are reviewed.

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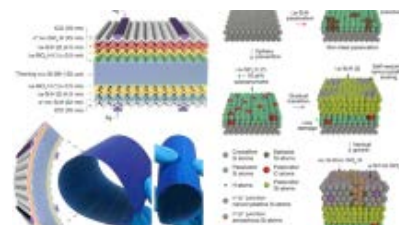
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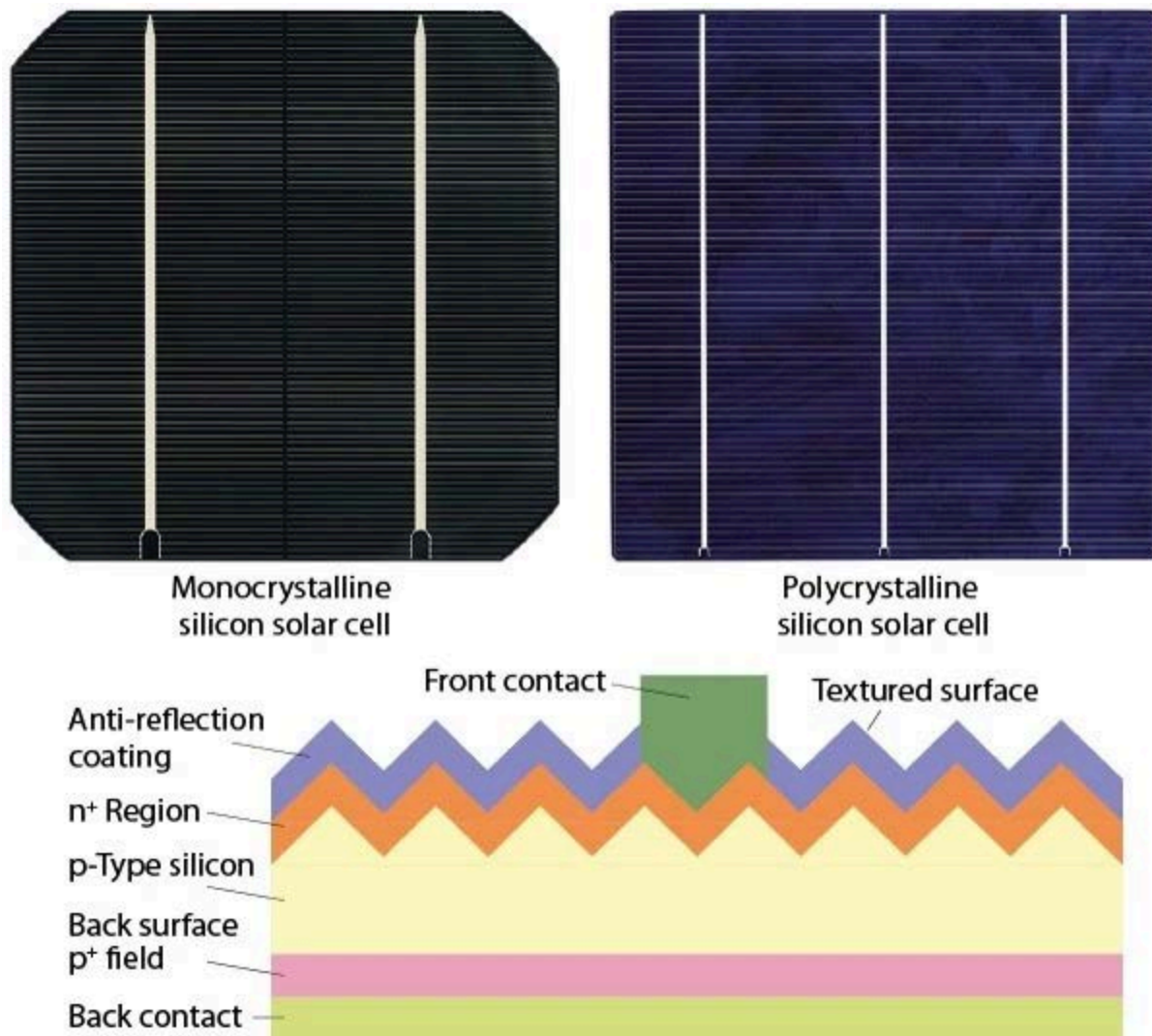
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Main

In 2008, the world annual production of photovoltaic (PV) cells reached more than 7.9 GW_p (W_p, peak power under standard test conditions)¹, and the average annual growth rate in PV cell production over the last decade has been more than 40%. Yet the electrical power generated by all PV systems around the world has been estimated to be less than 0.1% of the total world electricity generation¹. Nevertheless, the strong growth in PV cell production is expected to continue for many years. Crystalline silicon PV cells, with over 60 years of development, have the longest production history and now account for the largest share of production, comprising up to 90% of all the solar cells produced in 2008¹. Silicon is safe for the environment and one of the most abundant resources on Earth, representing 26% of crustal material. The abundance and safety of silicon as a resource grants the silicon solar cell a prominent position among all the various kinds of solar cells in the PV industry. World annual PV cell production of 100 GW_p is expected to be achieved by around 2020, and the silicon PV cell is the most viable candidate to meet this demand from the point of view of suitability for large-volume production.

The crystalline silicon PV cell is one of many silicon-based semiconductor devices. The PV cell is essentially a diode with a semiconductor structure ([Figure 1](#)), and in the early years of solar cell production, many technologies for crystalline silicon cells were proposed on the basis of silicon semiconductor devices. The synergy of technologies and equipment developed for other silicon-based semiconductor devices, such as large-scale integrated circuits and the many different kinds of silicon semiconductor applications, with those developed for PV cells supported progress in both fields. Process technologies such as photolithography helped to increase energy conversion efficiency in solar cells, and mass-production technologies such as wire-saw slicing of silicon ingots developed for the PV industry were also readily applicable to other silicon-based semiconductor devices. However, the value of a PV cell per unit area is much lower than that for other silicon-based semiconductor devices. Production technologies such as silver-paste screen printing and firing for contact formation are therefore needed to lower the cost and increase the volume of production for crystalline silicon solar cells. To achieve parity with existing mains grid electricity prices, known as 'grid parity', lower material and process costs are as important as higher solar cell efficiencies. The realization of high-efficiency solar cells with low process cost is currently the most important technical issue for solar cell manufacturers. Cutting the cost of producing expensive high-purity crystalline silicon substrates is one aspect of reducing the cost of silicon solar cell modules. This review covers the historical and recent technological advances in crystalline silicon solar cells from the perspective of industrial application.

Figure 1



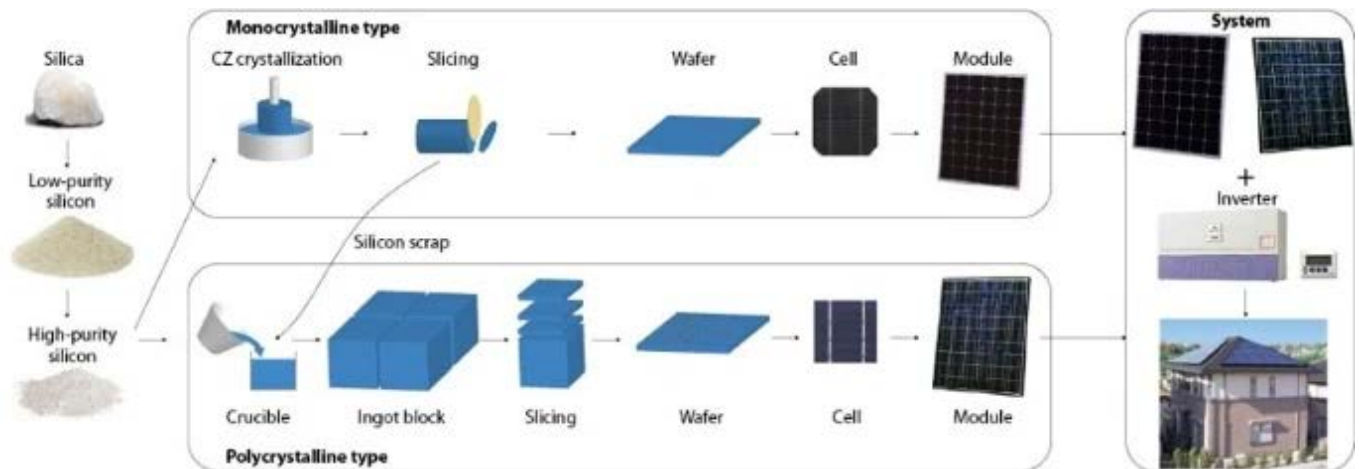
Typical mono- and polycrystalline silicon solar cells (upper), and simplified cross-section of a commercial monocrystalline silicon solar cell (lower) (© 2010 Sharp).

Features of standard crystalline-silicon PV cells and modules

Crystalline silicon PV cells are the most popular solar cells on the market and also provide the highest energy conversion efficiencies of all commercial solar cells and modules. The structure of typical commercial crystalline-silicon PV cells is shown in [Figure 1](#). Standard cells are produced using one of two different boron-doped p-type silicon substrates; monocrystalline and polycrystalline. The cells of each type are typically 125 mm (5 inches) or 156 mm (6 inches) square, respectively. Monocrystalline solar cells are produced from pseudo-square silicon wafer substrates cut from column ingots grown by the Czochralski (CZ) process (see [Figure 2](#)). Polycrystalline cells, on the other hand, are made from square silicon substrates cut from polycrystalline ingots grown in quartz crucibles. The front

surface of the cell is covered with micrometer-sized pyramid structures (textured surface) to reduce reflection loss of incident light. An anti-reflection coating (ARC) of silicon nitride (SiN_x) or titanium oxide (TiO_x) is overlaid on the textured silicon surface to further reduce reflection loss. Crystalline silicon solar cells have highly phosphorous-doped n_+ (electron-producing) regions on the front surface of boron-doped p-type (electron-accepting) substrates to form p–n junctions. Back-surface p_+ field (BSF) regions are formed on the back surface of the silicon substrate to suppress recombination of minority carriers (photogenerated electrons). The BSF regions are usually formed by firing screen-printed aluminum paste in a belt furnace. The carriers (electrons) generated in the silicon bulk and diffusion layers are collected by silver contacts (electrodes) formed on the front and back silicon surfaces. The front contact consists of gridlines connected by a busbar to form a comb-shaped structure. The back contact is usually a series of silver stripes connected to the front bus bar of the adjacent cell via soldered copper interconnects. The contacts are usually formed by firing of screen-printed silver paste at the same time as firing for formation of the BSF regions. The front contact is similarly formed using screen-printed silver paste applied on top of the ARC layer. Contact between the front electrode and the n_+ region of the silicon substrate is achieved by firing such that the silver penetrates through the ARC layer. The screen-printed front silver contact prepared by firing to penetrate the ARC is one of the most important techniques for large-volume fabrication of modern standard crystalline silicon cells. Other techniques, such as using boron-doped BSF and nickel–copper plating contacts, are used by a small number of cell manufacturers. The efficiencies of typical commercial crystalline silicon solar cells with standard cell structures are in the range of 16–18% for monocrystalline substrates and 15–17% for polycrystalline substrates. The substrate thickness used in most standard crystalline cells is 160–240 μm . The solar cells are assembled into modules by soldering and laminating to a front glass panel using ethylene vinyl acetate as an encapsulant. The energy conversion efficiency of modules of standard solar cells is roughly 2% lower than the individual cell efficiency, falling in the range of 12–15%.

Figure 2



Production process for typical commercial crystalline silicon solar cells (© 2010 Sharp)

The sequence of crystalline silicon solar cell production, from raw materials to modules, is shown in [Figure 2](#). The value chain for crystalline silicon solar cells and modules is longer than that for thin-film solar cells. There are generally three industries related to crystalline silicon solar cell and module production: metallurgical and chemical plants for raw material silicon production, monocrystalline and polycrystalline ingot fabrication and wafer fabrication by multi-wire saw, and solar cell and module production. The cost of PV production is roughly divided in half between solar cell module production and balance-of-system fabrication, which includes the inverter, cables and installation. The fabrication cost for solar cell modules includes the cost of the silicon substrate (50%), cell processing (20%) and module processing (30%). The cost share is therefore strongly affected by the market price for poly-silicon feedstock, and reducing the cost of the silicon substrate remains one of the most important issues in the PV industry.

The industrial goal for PV power is to reduce the electricity generation cost to the equivalent of that for commercial grid electricity. The energy conversion efficiency of solar cells is another important issue because the efficiency influences the entire value-chain cost of the PV system, from material production to system installation. The solar cell efficiency is limited by the three loss mechanisms: photon losses due to surface

reflection, silicon bulk transmission and back contact absorption; minority carrier (electrons in the p region and holes in the n region) loss due to recombination in the silicon bulk and at the surface; and heating joule loss due to series resistance in the gridlines and busbars, at the interface between the contact and silicon, and in the silicon bulk and diffusion region. In the design of solar cells and processes, these losses are minimized without lowering the productivity of the solar cells.

The electrical performance of a solar cell is determined by the short-circuit current (I_{sc}), open-circuit voltage (V_{oc}), current at the maximum power point (I_{mp}), voltage at the maximum power point (V_{mp}), maximum power (P_{max}), fill factor (FF) and energy conversion efficiency (η). In research and development, short-circuit current density (J_{sc}) is also used. An air mass 1.5 (AM_{1.5}) spectrum condition (1,000 W m⁻²) is the standard test condition for terrestrial solar cells. The AM_{1.5} condition is defined as 1.5 times the spectral absorbance of Earth's atmosphere; in contrast, the spectral absorbance for space is zero (air mass zero, AM₀). The solar energy under the AM_{1.5} condition is used as the input energy for calculation of solar cell efficiency. The solar cell fill factor and efficiency are calculated using the following equations.

$$FF = \frac{P_{max} [W]}{I_{sc} [A] \times V_{oc} [V]} ; (P_{max} [W] = I_{mp} [A] \times V_{mp} [V])$$

$$\eta [\%] = \frac{P_{max} [W] \times 100}{1,000 [Wm^{-2}] \times Cell\ area [m^2]}$$

(1)

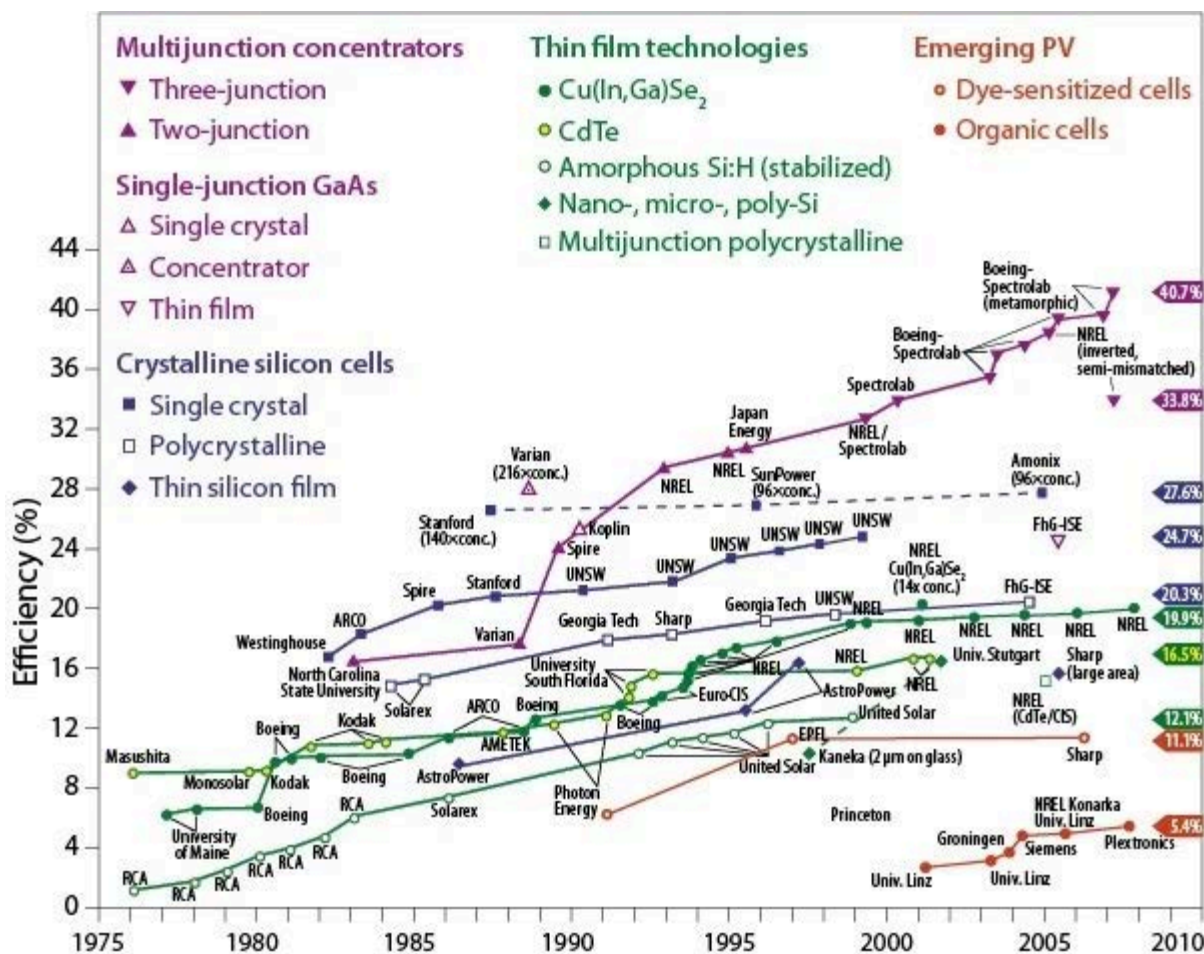
Efficiency improvements

Historical development

Bell Laboratory fabricated the first crystalline silicon solar cells in 1953, achieving 4.5% efficiency, followed in 1954 with devices with 6% efficiency [2,3]. In the ten years since the first demonstration, the efficiency of crystalline silicon cells was improved to around 15%, and were sufficiently efficient to be used as electrical power sources for spacecraft, special terrestrial applications such as lighthouses, and consumer products such as electronic calculators. The improvements in research-cell efficiencies achieved for various

kinds of solar cells over the past 30 years are shown in [Figure 3](#). Although crystalline silicon solar cell technologies are not yet as efficient as cells based on single-junction GaAs and multi-junction concentrators, they currently provide a good compromise between efficiency and cost.

Figure 3



Best research solar cell efficiencies reported by NREL (© 2010 NREL)

The basic cell structure used in current industrial crystalline solar cells, which includes features such as a lightly doped n₊ layer (0.2–0.3 μm) for better blue-wavelength response, a BSF formed by a p/p₊ low/high junction on the rear side of the cell, a random pyramid-structured light-trapping surface, and an ARC optimized with respect to the refractive index of the glue used to adhere it, were developed for space and terrestrial

use in the 1970s. The efficiency of monocrystalline cells for space use is in the range of 14–16% under '1 sun' AM_0 test conditions, equivalent to 15–17% at $AM_{1.5}$. These standard structures for crystalline silicon cells are still used in standard industrial crystalline cells, which offer efficiencies in the range of 14–17%.

The key technologies needed to realize efficiencies of higher than 20% were developed in the 1980s and '90s, and the latest high-efficiency crystalline silicon cells possess most of these features ([Table 1](#)).

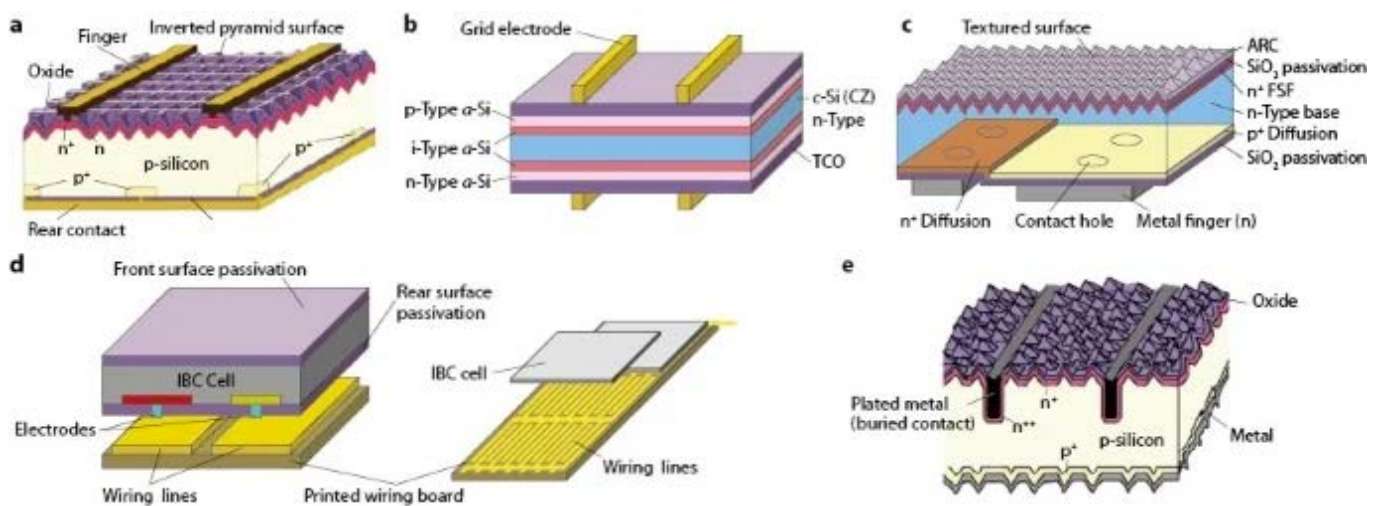
Table 1 Key technologies for high-efficiency crystalline silicon solar cells

Monocrystalline solar cells

Representative examples of high-efficiency monocrystalline silicon PV cells are the passivated emitter rear localized (PERL) cell, the heterojunction with intrinsic thin layer (HIT) cell, and the back contact, back junction (BC-BJ) cell ([Figure 4\(a,b,c\)](#)). These PV cells feature many of the technologies that provide high efficiency in this type of PV cell. The PERL cell is a research PV cell with front and rear surface passivation layers, an inverted-pyramid light-trapping surface, a rear localized p_+ layer (BSF), a double-layer ARC and p-type float zone (FZ) monocrystalline silicon substrate. The bulk minority carrier lifetime in PERL cells is longer than 1 ms, and the best output parameters (V_{oc} , J_{sc} , FF and η) achieved for this type of cell are 706 mV, 42.7 mA cm^{-2} , 0.828 and 25.0% for a 4 cm^2 laboratory cell⁴. This cell approaches the limit of current technologies for the absorption of solar photons and the collection of carriers generated in the cell emitter and base. A PERL cell efficiency of 24.7% was reported almost ten years ago, and the record of 25.0% reported by researchers from the University of New South Wales (UNSW) in 2009 was obtained after re-measurement of the same cell using newer measurement techniques. The PERL cell has remained the most efficient type of monocrystalline-silicon PV cell for the past ten years⁵, and has been the most popular laboratory structure of all the high-efficiency crystalline silicon PV cells. However, the full PERL design is not easy to apply to

low-cost industrial production because of the necessity for multiple photolithography steps, similar to semiconductor devices with complex structures. Expensive silicon PV cells for space applications have a similar structure to the PERL cell⁶. The PLUTO cell developed for industrial use by SunTech Power has a simpler passivated emitter solar cell (PESC) design, which was also developed at the UNSW in 1985⁷, and provides efficiency of up to 19.2% in a 4 cm-square cell⁸. The PESC features front passivation, a selective emitter, and a plated front contact with fine gridlines.

Figure 4



Schematics of various crystalline solar cell structures. (a) PERL. Adapted from Ref. [5](#) (© 1999 Wiley-VCH Verlag GmbH & Co. KGaA). (b) HIT. Adapted from Ref. [48](#) (© 2008 WIP Munich). (c) BC-BJ. Adapted from Ref. [49](#). (d) interdigitated back-contact (IBC) cell using surface mount technology. Adapted from Ref. [17](#) (© 1976 IEEE). (e) Buried-contact cell structure by BP Solar. Adapted from Ref. [40](#) (© 2008 IEEE). All figures reproduced with permission.

The best output parameters reported for the HIT cell, which was developed for industrial use, are 729 mV, 39.5 mA cm⁻², 0.800 and 23.0% (V_{oc} , J_{sc} , FF and η) for a large 100.4 cm² cell⁹. This cell has a unique heterojunction structure consisting of very thin, amorphous p- and n-doped layers and intrinsic amorphous layers on the front and rear surfaces of a CZ n-type monocrystalline-silicon substrate. This heterojunction structure improves V_{oc} considerably by the effects of the large energy bandgap of the front amorphous silicon

layer and the excellent quality of the interface between the amorphous layer and the crystalline substrate. This cell has the additional advantage of a low temperature coefficient of about $0.30\% \text{ K}^{-1}$ at P_{max} compare to about $0.45\% \text{ K}^{-1}$ for standard industrial crystalline silicon PV cells. This cell has a transparent conductive oxide (TCO) ARC, which reduces the sheet resistivity of the front amorphous layers. The distinctly lower J_{sc} compared to other high-efficiency PV cells appears to be due to suppressed photocurrent collection by the front amorphous silicon layers and the bulk silicon by the effects of the lower transparency of the TCO layer compared to other ARCs and/or the lower internal quantum efficiency of the amorphous layers. The result is a weaker blue response and lower J_{sc} .

The BC-BJ cell has interdigitated n- and p-doped regions and n and p contacts on the back surface. The original BC-BJ cell, called the front surface field (FSF) cell or interdigitated back contact (IBC) cell, was fabricated and studied for space applications in the late 1970s [10,11]. The BC-BJ-structured point contact (PC) cell developed by Stanford University in the 1980s gave efficiencies of more than 20% from the outset¹². BC-BJ cells were first fabricated for unmanned aircraft and solar race cars by SunPower in the 1990s. The cells were then extended to large-scale production for PV generation systems in the 2000s. The best conversion efficiency reported so far for a large-area industrial BC-BJ cell is 23.4%¹³. The BC-BJ cell has front and rear surface passivation layers, a random-pyramid light-trapping surface, FSF, interdigitated n- and p-doped regions on the back surface, n and p contact gridlines on n- and p-doped regions, a single-layer ARC and CZ n-type single-crystalline silicon substrate with a minority carrier lifetime of longer than 1 ms. Of all the crystalline silicon PV cell modules on the market at this time, only those based on BC-BJ cells provide the possibility of module efficiencies exceeding 20%. Several laboratories and manufactures are studying methods for improving the design and processing of BC-BJ cells [14,15]. BC-BJ cells have several advantages compared to the conventional front-contact cell structure: no gridline (sub-electrode) or busbar (main electrode) shading, a front surface with good passivation properties due to the absence of front electrodes, freedom in the design of back contacts (electrodes), and improved appearance with no front electrodes. They also provide

advantages in module assembly, allowing the simultaneous interconnection of all cells on a flexible printed circuit (see [Figure 4\(d\)](#)). The low series resistance of interconnection formed by this type of surface-mount technology results in a high FF of 0.800, compared with around 0.75 for standard silicon PV cell modules [16,17].

Industrial cells

Monocrystalline solar cells

p-Type monocrystalline substrates sliced from boron-doped CZ ingots have been used for standard industrial PV cells for many years. In the early era of terrestrial PV cell production, small 2–5-inch-diameter CZ ingots were used, the small size and high cost of which obstructed cost reduction for monocrystalline cells. Much research and development has been devoted to reducing the production costs for CZ ingots and wafer processing over the past 20 years. CZ wafers with side lengths of 125 and 156 mm, sliced from 6- and 8-inch-diameter ingots, respectively, are now widely used for monocrystalline silicon PV cell fabrication. The fabrication of monocrystalline cells and modules using wafers of the same size as those used for polycrystalline cell production has improved the competitiveness of monocrystalline cells against their polycrystalline counterparts in terms of manufacturing cost per output watt. Monocrystalline cells represented 38% of all solar cells manufactured in 2008¹.

There are large differences between the efficiencies of the best research crystalline silicon PV cells and the corresponding industrial cells. The efficiencies of standard industrial monocrystalline PV cells remain in the range of 16–18%, considerably lower than the 25% efficiency levels of the best research cells. Industrial cells are restricted by economic factors to simple cells that are suitable for high-speed, automated production using low-cost materials. Simple design features, such as front surface texturing and BSF similar, to those developed for terrestrial crystalline-silicon PV cells in the early 1980s are still adopted in most current industrial crystalline cells. To improve cell efficiencies, many cell manufactures are systematically attempting to introduce high-efficiency features, such as finer gridlines, selective emitters or more shallowly doped n_+ regions, into existing manufacturing processes. The BC-BJ cells and HIT cells have exceptionally high

efficiencies for industrial monocrystalline PV cells, but have complex cell structures that require a much longer production process and more specialized equipment compared with the other industrial cells. As a result, it is difficult for these advanced cell types and modules to compete commercially in terms of production cost per output watt. There remains a dilemma in the balance between efficiency improvement and cost reduction for solar cells and modules using existing manufacturing technologies. Innovative and simple manufacturing technologies and equipment for the fabrication of high-efficiency solar cells are therefore needed in order to realize significant cost reductions for the production of crystalline silicon PV modules.

Another drawback of the monocrystalline cell technologies is that monocrystalline cells based on p-type CZ silicon substrates are susceptible to light-induced degradation (LID) caused by the recombination of reactive boron–oxygen complexes ($B-O_2$). Many studies have been undertaken in attempts to eliminate LID effects in monocrystalline-silicon PV cells, and permanent deactivation of the complex at high temperature ($> 170^\circ\text{C}$) has been reported¹⁸. Boron-doped magnetic-field CZ wafers and gallium-doped CZ wafers also show promise for eliminating LID effects in monocrystalline solar cells, and CZ-silicon cells based on phosphorous-doped n-type CZ wafers are also free of LID effects. The high-efficiency PV cells of SunPower and Sanyo are made using n-type CZ-silicon wafers.

Polycrystalline solar cells

Polycrystalline silicon ingots and wafers were developed as a means of reducing the production costs for silicon ingots, and have been investigated since the mid-1970s [19,20]. Modern polycrystalline furnaces are designed for maximum productivity, casting ingots of around 450 kg. Polycrystalline cells are currently the most widely produced cells, making up about 48% of world solar cell production in 2008¹. Standard polycrystalline industrial cells offer efficiencies of 15–17%, roughly 1% lower than for monocrystalline cells fabricated on the same production lines. The efficiencies of polycrystalline cell modules, however, are almost the same as those for monocrystalline

cells (14%) due to the higher packing factor of the square polycrystalline cells; monocrystalline cells are fabricated from pseudo-square CZ wafers and have relatively poor packing factors.

The efficiencies of both monocrystalline and polycrystalline PV cells will be improved in the future through the introduction of high-efficiency structures. The difference in efficiency between monocrystalline and polycrystalline cells is expected to become larger with the introduction of such high-efficiency structures due to the difference in crystal quality (*i.e.* minority carrier lifetimes). The best of the current research polycrystalline silicon cells, a PERL cell developed by Fraunhofer ISE²¹, provides an energy conversion efficiency of 20.3%. This PERL cell has a laser-fired contact back structure that gives a V_{oc} of as high as 664 mV. The efficiency of this polycrystalline cell, however, remains about 5% lower than that for the best of the research monocrystalline PERL cells, attributable mainly to the quality difference between mono- and polycrystalline substrates. Polycrystalline substrates are subject to higher rates of minority carrier recombination, both at active grain boundaries and within crystalline grains due to high dislocation and impurity densities in comparison with FZ or CZ monocrystalline substrates. A considerable amount of research and development has been conducted on improving the efficiencies of polycrystalline solar cells over many years, by both public and industrial laboratories, and recent high-efficiency polycrystalline silicon solar cells now have the features listed in [Table 2](#). These features are generally the same as for recent monocrystalline solar cells.

Table 2 Key technologies for high-efficiency polycrystalline silicon solar cells

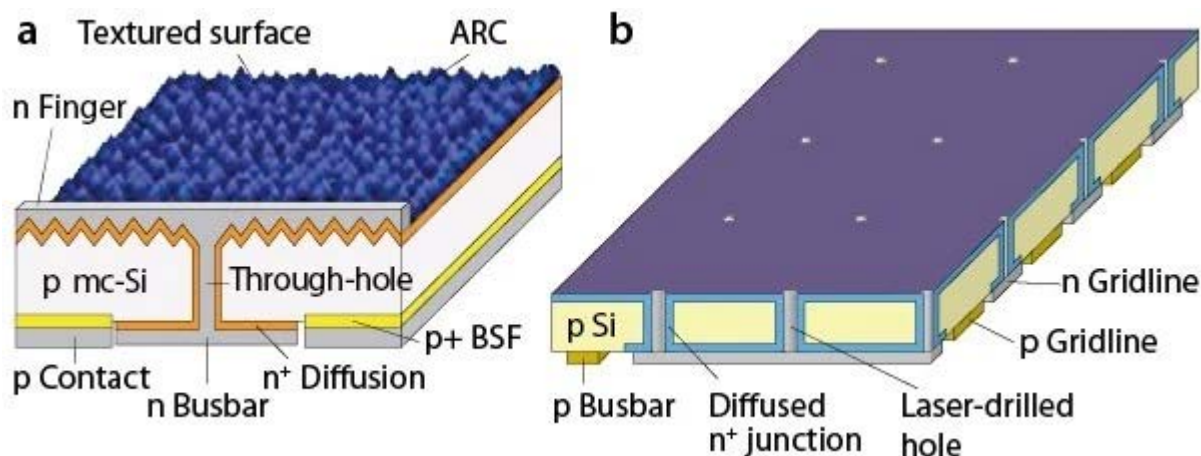
The honeycomb-structured polycrystalline solar cells demonstrated recently by Mitsubishi Electric exhibit efficiencies of over 19.3% and come in large 15 cm × 15 cm cells²². These polycrystalline cells have a distinct front honeycomb-textured surface to reduce light reflection, and the introduction of this front textured surface has resulted in a high J_{sc} of 37.5 mA cm⁻² for cells with screen-printed and fired silver-paste electrodes.

This cell also has the PERL structures of front surface passivation, rear surface passivation with local BSF, and a selective emitter for improved cell efficiency.

Approaches to reduce cell costs also include using thinner silicon wafers. High-efficiency (18.1%) polycrystalline silicon cells fabricated using 100 μm -thick wafers were reported by Sharp in 2009²³. The electrical performance of crystalline silicon PV cells with the standard back surface structure of an aluminum-alloyed BSF decreases as the substrate becomes thinner. High-efficiency polycrystalline cells with an SiN_x passivation layer and thin aluminum reflector on the back silicon surface display less of a performance degradation with decreasing substrate thickness for substrates of 100–180 μm in thickness. Cells with rear passivation and local BSF on 100 μm -thick substrates provide the additional advantage of less cell bowing compared with the standard aluminum alloyed BSF cells on substrates of the same thickness.

New types of back-contact polycrystalline cells, such as metal wrap through (MWT) cells and emitter wrap through (EWT) cells ([Figure 5](#)), have also been developed by institutes and companies such as ECN, Kyocera and Advent Solar [24–26]. BC-BJ cells without a front p–n junction require high-quality monocrystalline substrates with high minority carrier lifetimes. The WT back-contact cells, however, are suitable for use with polycrystalline substrate having relatively short minority carrier lifetimes (related to cell thickness). The front p–n junctions in these cells can collect most carriers generated in the region from the front n-doped layer to the back substrate surface. These back-contact cells have laser-drilled through-holes that can wrap through front n-electrodes and/or n-doped regions to the back surfaces. The MWT cells require only a relatively small number of through-holes to direct photogenerated electrons to the back surface through the metal electrodes and n-doped emitters, and produce higher collection photocurrents due to absence of a bus bar (main electrode) on the front surface as in conventional cells. A high J_{sc} of 37.3 mA cm^{-2} and an efficiency of 18.3% were reported for a recent MWT cell by Kyocera²⁶, and the module efficiency for MWT cell modules by ECN, 16.4%, is the highest reported to date²⁵.

Figure 5



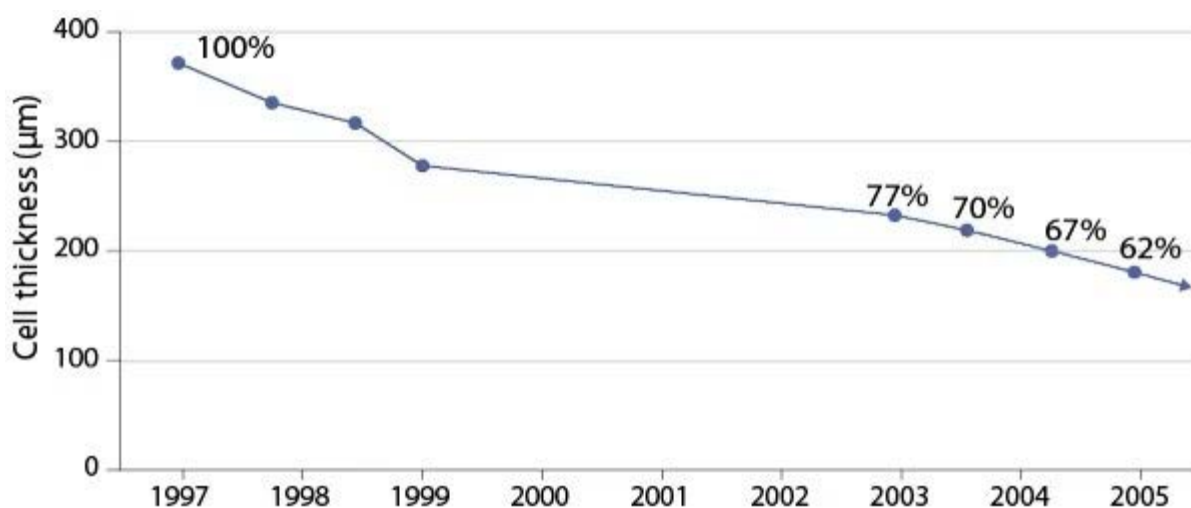
Schematics of back-contact solar cell structures. (a) MWT. Adapted from Ref. [26](#) (© 2008 WIP Munich). (b) EWT. Adapted from Ref. [25](#) (© 2008 IEEE). All figures reproduced with permission.

The EWT cells have a larger number of close-spaced through-holes, which direct photogenerated electrons to the back surface solely through n-doped emitters. The EWT cells produce even higher photocurrents by eliminating the both busbar (main electrode) and gridline (sub-electrode) shading on the front surface. A high J_{sc} of 37.5 mA cm⁻² and efficiency of 17.1% were reported recently for EWT cells by Q-Cells. The target for industrial polycrystalline PV cells is to realize average cell efficiencies of 17% in large-scale production^{[24](#)}.

Many methods have been investigated to improve the quality of polycrystalline substrates to match that of the more expensive CZ monocrystalline wafers. The dendritic casting method is one such approach that allows the grain orientation and size to be controlled, resulting in high-quality dendritic crystals with parallel twinning. Solar cells based on dendritic polycrystalline wafers show efficiencies of as high as 17%, comparable to the efficiencies provided by CZ monocrystalline cells using the same cell fabrication process^{[27](#)}.

The raw, high-purity polysilicon material used for the fabrication of crystalline silicon solar cells is generally made by the Siemens method. The market price for raw silicon is affected by the demand–supply balance for solar cell and semiconductor fabrication, and can fluctuate markedly. In 2006–2008, for example, the cost of raw silicon as a proportion of total solar cell module cost jumped from 20–30% to more than 50% due to a market shortage of silicon. Reducing the cost of silicon in a cell module by reducing the substrate thickness is therefore an important aspect of achieving overall cost reductions for solar cell modules. Wire-saw wafer slicing is one of the key production technologies for industrial crystalline silicon PV cells, and improvements in wafer slicing technology have resulted in a reduction in raw wafer thickness from 370 μm to 180 μm since 1997 for Sharp industrial polycrystalline-silicon cells ([Figure 6](#)). To introduce wafers thinner than 150 μm , sophisticated manufacturing processes suitable for ultrathin wafers will be needed, and the processes will need to provide high processing speed and high manufacturing yield in each of the process steps of wafer slicing, cell fabrication and module assembly.

Figure 6



Reduction of silicon wafer thickness by Sharp (© 2010 Sharp)

Several alternative growth methods have been proposed over the past four decades for the production of polycrystalline substrates directly from molten silicon, including edge-defined film-fed growth (EFG), string ribbon growth (SRG), and ribbon growth on substrate (RGS) [28–30]. These methods potentially make it possible to reduce the amount of silicon used in PV cell fabrication. The EFG and SRG methods are used on industrial production scales by SCHOTT Solar and Evergreen Solar, respectively³¹. These two methods have the advantages of low silicon consumption per W_p and high cell efficiencies in comparison with the RGS method. These methods afford inexpensive but slightly wavy polycrystalline substrates in comparison with the standard polycrystalline substrates. Recently manufactured cells based on direct-grown substrates have almost the same efficiencies as those of standard cast-silicon polycrystalline cells. However, the smaller EFG- and SRG-based cells, which are roughly half the size of standard industrial cells, incur higher cell and module processing costs. A crystallization on dipped substrate method, which can be used to produce standard-sized wafers (156 mm × 156 mm) directly from molten silicon in a crucible, was recently proposed by Sharp³².

The front emitter layer of crystalline silicon PV cells is formed by phosphorus diffusion techniques in a quartz tube or belt furnace. Solid P_2O_5 or liquid $POCl_3$ is used as the phosphorus diffusion source. Phosphorous diffusion techniques the exploit gettering effects to reduce impurity densities in a silicon wafer and thereby improve minority carrier lifetime have been demonstrated to be effective provided diffusion is conducted under phosphorus supersaturation conditions (doping level above the solid solubility in silicon) [33–35].

The BSF layers in industrial cells are formed by alloying of screen-printed aluminum paste in a belt furnace. This process provides high productivity and relatively low process cost for BSF formation. Aluminum-paste alloying has the additional advantage of inducing wafer gettering effects in both polycrystalline and monocrystalline silicon PV cells similar to the phosphorus diffusion technologies [36,37]. Metal impurities, such as iron or copper, can be eliminated from bulk silicon by aluminum gettering effects, which can improve the minority carrier diffusion length.

The screen printing and firing of silver paste to make contact with the bulk silicon surface by penetrating the ARC is a well-established, simple and fast process for forming front and rear electrodes. It is also the most widely used and lowest-cost method for forming electrodes in industrial crystalline silicon PV cells. The front gridlines are designed so as to optimize the trade-off between shadow loss and series resistance. As an alternative to the screen-printed silver paste approach, plated electrodes of layered nickel, copper and silver have been developed by researchers at the UNSW for use in buried-contact (BC) cells [38,39]. The BC cell fabricated by BP Solar is shown in [Figure 4\(e\)](#)⁴⁰. Crystalline silicon PV cells with plated electrodes have excellent electrical characteristics due to their low series resistance and fine gridlines, which result in a much smaller shadow area. However, plated electrodes, which are formed by a wet process, have not yet become as widely used as the screen-printed silver paste electrodes. The silver used as the electrode material in crystalline silicon cells will become a critical material resource when crystalline silicon solar cell production reaches the large volumes predicted in the future. Copper and aluminum have therefore been considered as substitutes for silver in silicon PV contacts.

Future views on crystalline silicon solar cells

Industrial solar cells module must reach a price level of $\$1/W_p$ with a total system price level of $\$2/W_p$ to reach grid parity, and to become competitive with coal or nuclear power generation will need to be mass produced at a total system cost of less than $\$1/W_p$. Achieving even a module price of $\$1/W_p$ will require modules to be produced at a cost of less than $0.7\$/W_p$. Although such low costs remain very challenging for modules based on crystalline silicon solar cells, cost reductions to such a level are considered to be possible based on the technologies presented in this review, and the cost reduction must be accomplished while public incentives for PV systems remain in effect. The annual production volume for all kinds of solar cells is expected to exceed 100 GW_p /year by around 2020. Crystalline silicon cell modules have a long history of proven field operation and offer high efficiencies while presenting fewer resource issues than many competing technologies. As such, crystalline silicon PV cells are expected to be strongly represented in the future solar cell market.

To reach these future price levels, new technologies as listed in [Table 3](#) will be needed for crystalline silicon solar cells and modules. New technologies to break through the efficiency barrier of 25% for crystalline silicon PV cells are being studied by many researchers and institutes around the world, but there have yet to be any practical improvements in cell efficiency. The peak theoretical efficiency in a crystalline silicon solar cell based on a single homojunction and a bulk silicon energy bandgap of 1.1 eV is 30% under 1 sun AM_{1.5} illumination. To break through this ideal efficiency limit based on existing Shockley and Queisser solar cell theory, novel technologies based on quantum dot (QD) and quantum well structures have been proposed and studied by many researchers. Multi-junction designs have been attempted in many forms for improving solar cell efficiency beyond that of a single-junction cell. For example, a triple-junction solar cell with a silicon bottom cell is expected to give efficiencies of more than 40%. Researchers at the UNSW have also proposed a silicon-based tandem junction solar cell incorporating silicon QD technology⁴¹. An effective bandgap of up to 1.7 eV has been demonstrated for 2 nm-diameter silicon QDs embedded in SiO₂⁴². Photon management, such as up- and down-conversion and plasmonic effects, are other potential approaches that could add extra efficiency based on existing high-efficiency silicon cells [43–45]. These technologies aim at shifting the photon energy of sunlight to match the sensitivity of the solar cell by adding special optical features (e.g. a fluorescent coating layer including rare-earth elements for up-and down-conversion) to the front and/or rear surface of the cells without modifying the structure of the solar cell itself.

Table 3 New technologies for high-efficiency crystalline silicon solar cells and modules

These high-efficiency technologies, however, generally incur higher production costs compared to standard silicon cells. Cell and module manufacturing technologies that satisfy both high efficiency and low cost will be essential for industrial production in the near future. The impacts of novel technologies such as QDs and photon management will

be interesting to watch as research and development on crystalline silicon solar cells continues.

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